# EV37.1471585

DECLARATION OF LUAN C. TRAN UNDER 37 C.F.R. §1.131 - SUBMITTED WITH THE RESPONSE TO JULY 13, 2004 OA

MI22-1921

#### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No
Filing Date February 8, 2002
Inventor Luan C. Tran
Assignee Micron Technology, Inc.
Group Art Unit
Examiner L.M. Schillinger
Attorney's Docket No
Title: A Plurality of Transistors Having Different Active Area Widths and Different
Threshold Voltages Defined by STI

### DECLARATION OF LUAN C. TRAN UNDER 37 C.F.R. §1.131

- I, Luan C. Tran, hereby swear and state that:
- 1. I am the inventor of the subject matter of the above-referenced application, as evidenced by the invention disclosure attached hereto as Exhibit "A".
- 2. Prior to September 28, 1998, I conceived the subject matter of the above-referenced invention while working in my laboratory in Bolse, Idaho at my place of employment Micron Technology, Inc., as evidenced by the accompanying invention disclosure (Exhibit A).
- 3. Prior to September 28, 1998, I reduced the subject matter of the above-referenced application to practice in my laboratory in Boise, Idaho, at my place of employment Micron Technology, Inc., as evidenced by the accompanying invention disclosure (Exhibit A).

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- The pertinent dates deleted from Exhibit "A" are prior to 4. September 28, 1998.
- I hereby declare that all statements made herein of my own 5. knowledge are true and that all statements made on information and belief are believed to be true and, further, that these statements were made with knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under §1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

DATED: De 8 th 2004 By: LUA

#### EXHIBIT A

# Micron Confidential and Proprietary Information



# INVENTION DISCLOSURE

1. INVENTOR(S):

Luan C Tran

- 2. DESCRIPTION:
  - Title:

Low Vt Transistor Using STI Reverse Narrow Width Effects

Brief Description:

Using Reverse Narrow Width with STI process to achieve Lower Vt without using an additional mask. The current drive can be achieved using multiple narrow width devices in parrallel. This invention is useful for low Vtn precharge circuit or output driver where Low Vt is important to obtain higher signal level, due to Vt drop.

- 3. CONCEPTION & DOCUMENTATION OF INVENTION:
  - Date when first conceived:
  - To whom was the idea first described:
    - M. McQueen
  - On what date:

  - Date of the first tangible record:

  - Type and location:

Param Data from X59 lot.

- 4. INFORMATION RELATED TO INVENTION:
  - Related invention disclosures:

02/21/2006 17:38 FAX 5098383424 invention Disclosure Form System

N/A

• Closest technology:

STI Isolation

Advantages of this invention over previous technology:

No mask is needed to form Low Vt devices, important for low voltage applica

#### 5. IMPORTANT DATES:

• If the invention has been disclosed outside the company, please specify to whom it has been disclosed, when, and in what form:

N/A

 If any articles describing your invention have been published, please specify the author(s), title of article, publication and date:

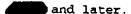
N/A

• If any engineering samples have been given out, please specify to whom and on what date they were given:

Param Results

#### 6. DISPOSITION OF THE INVENTION:

- When will (or did) Micron begin use of the invention experimentally:
- with X59 data.
- When will (or did) Micron begin production of this invention:



#### 7. MISCELLANEOUS INFORMATION:

- ARPA project:
- Was the invention developed during a joint development agreement or other contract with an outside company:

No

 List developmental work outside of the company, including Government proposal or contract:

No

#### 8. INVENTORS:

Name : Luan C Tran Home Address : 1125 W. Sandy Ct

City: Meridian State: ID Zipcode: 83642

Citizenship : US

Company : Micron Technology, Inc.

Work Phone # : 368-4708 Mail Stop : 840 Dept # : 850G

Dept Name : Process R&D

Supervisor : Mark Durcan

Signature : \_

#### 9. WITNESS:

If there is only one (1) inventor, a witness should sign and date this disclosure. A witness in this case is a non-inventor who understands the nature of the invention

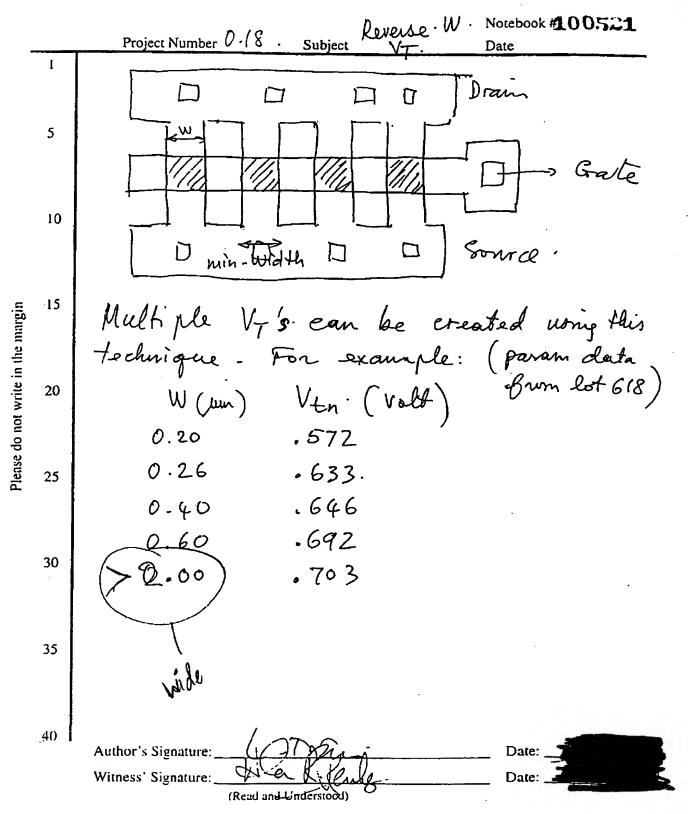
( Signature of Witness )

## ◆ ◆ ◆ Restricted — Do Not Reproduce ◆ ◆ ◆

·	.:·	Project Number 0-18 Subject Using Narrow Date
Please do not write in the margin	1	
	5	In Shallow Trench Isolation, it is known that bevice with marrow width has lover threshold wiltage (Vt) q [This is in
	10	Contrast with the conventional LOCOS  Isolation where Vt increases with decreasing
	15	This effect in shallow trench islation is referred to as reverse narrow
	20	In low voltage design, it is desirable to have low by for applications such
	25.	
	30	proprie in this disclosure is a method.
	35	on additional photo mask.
	40	Author's Signature:  Witness' Signature:  Date:

(Read and Understood)

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